

# Body biasing injection: analysis, modeling and simulation (MAX 14 PAGES)

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**Abstract**—This is the abstract.

Orange text is for undecided wording/words.

Red text is for important messages.

Cyan text is for future bib references to add.

**Index Terms**—Article submission, IEEE, IEEEtran, journal, LATEX, paper, template, typesetting.

## I. INTRODUCTION

WHEN working with cybersecurity, specifically with hardware security, various fault injection methods are often considered. One can point out Electromagnetic Fault Injection (EMFI) [1], [13], Laser Fault Injection (LFI) [2], or Body Biasing Injection (BBI) [3], not to cite them all. The current work is dedicated in studying Body Biasing Injection.

Nowadays, electronic devices are found in every economic sector, and very often they manipulate sensitive data, such as in bank transactions, Internet of Things (IoT) devices, or smartphones. To ensure data authenticity, these devices embed cryptographic algorithms. While theoretically secure, once implemented on actual devices, these algorithms become fallible, leaking manipulated data, in addition to being sensitive to external disturbances.

### A. Fault injection objectives

Fault injection methods are set up to perform various malicious manipulation on integrated circuits, such as:

- Denial of service (DoS) → Stop circuit operation and the related services;
- Verification bypass → Modify data on the fly to fake authenticity (e.g. to bypass bootloader security);
- Confidential data extraction → Modify data to perform differential fault analysis.

### B. BBI in the state-of-the-art

When compared to EMFI, BBI has a smaller state-of-the-art, whether in the amount of scientific papers published or in the amount of industrial platforms proposed. Currently, there are ten main works lingering on BBI [3]–[12]. Each one of them made a unique contribution for a better understanding of BBI.

The first one [3] introduced the technique and presented a Bellcore attack on the targeted IC. Then, one year later, another work [4] further studied the method, followed by a third work three years later [5], introducing an advanced test bench to work and perform attacks with BBI.

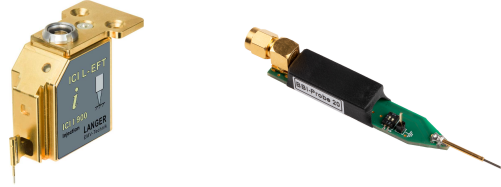


Fig. 1. Langer and Riscure BBI probes.

riscure\_langer

However, there are still unanswered questions, and the current works aim at bringing more answers thanks to previous and new data.

Before introducing the present work, let us eventually analyze the industrial platforms proposed by various manufacturers and introduce our own test platform. We can distinguish three major actors proposing BBI related products:

- Langer EMV-Technik;
- Riscure;
- NewAE Technology.

1) *Langer EMV-Technik platform*: The German society Langer EMV-Technik proposes an all-in-one and ready-to-use BBI platform composed of two hardware tools:

- A current pulse generator with a metal needle, shown in left in Fig. 1;
- A general controller called "Burst Power Station", combining a power supply, control and monitor tool and a software.

### C. BBI interrogations

With all the work in the state-of-the-art in mind, there are still remaining questions unanswered about BBI, such as:

- What is the spatial resolution of BBI?
- What is the time resolution of BBI?
- Is thinning the substrate useful in any way?
- How BBI induced faults occur?
- How to properly model BBI?

## II. MODELING AND SIMULATING BBI

SIMULATING a fault injection method behavior is an important part in understanding its mechanisms. Whether it is EMFI, LFI or BBI, it allows to predict and understand the underlying phenomena at work to set up reliable experiments. In this paper, we are focusing solely on BBI.

Ideally, we would want to directly observe signals inside integrated circuits, allowing for fine measurements of power supply voltages, logic levels and power current not to cite

every physical quantity. However, embedding sensors into an already existing IC is not possible, and doing so on future IC is costly and takes time to fully implement. In addition to this, we do not have any guarantee that these sensors will not be disturbed too much by the fault injection. Therefore, we have decided to take the following approach:

Simulation → Conclusions → Verification

By doing so, we have freed ourselves from hardware limitations. However, other limitations remains. Indeed, modern ICs, even the smallest, embed millions of transistors, and with current technologies, it is impossible to evaluate with simulations entire circuits at a transistor level. Therefore, to tackle these limitations, we decided to adopt an hybrid approach, combining transistor-less models and local logic gates simulations. This approach is a compromise between accuracy and computational cost/time, and allows simulating relatively big circuits under BBI disturbances. Overall, it is similar to what has been done for EMFI in [1]. The resulting simulation flow is divided in three consecutive steps:

- The simulation of an IC under BBI using a transistor-less model, allowing for a purely electrical analysis;
- The extraction of significant disturbed signals from the previous simulation;
- The simulation of functional logic gates under BBI thanks to the previously extracted signals.

#### A. An hybrid simulation flow: building the models

Building the correct models for the simulation flow pass through multiple steps. As the goal of the hybrid flow is to reduce the computational power required to evaluate an IC, it is still important to maintain a certain accuracy concerning the IC physical structure. To do so, the models are designed around actual IC implementations. The main building blocks of the models are the power supply network, the standard-cells, and the substrate structure. In this work, we are only focusing on bulk substrates: specifically dual-well and triple-well substrates.

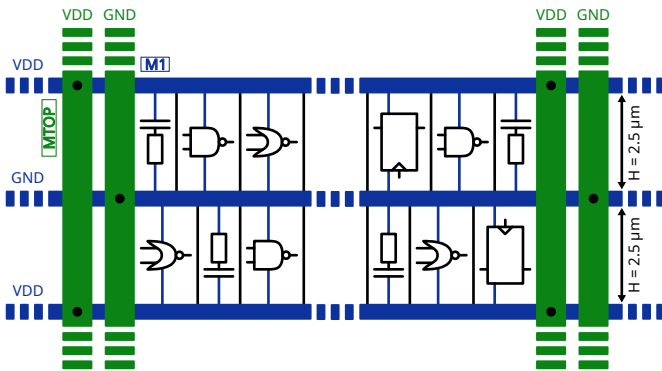


Fig. 2. A Standard-Cell Segment and its power delivery network

#### 1) Power supply rails: Fig. 2

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